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| To Examiner: Thanhha S. Pham | Total Pages Sent: 12 |
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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Schwalbe, *et al.* Docket No.: INF-119
Serial No.: 10/724,141 Art Unit: 2813

Date Filed: December 1, 2003

TITLE: Method For Patterning Dielectric Layers On Semiconductor Substrates

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- Certification of Facsimile Transmission (1 page)
- Amendment (11 pages)

Respectfully submitted,

Kristy Engeldahl

Kristy Engeldahl
Legal Assistant

Confirmation Respectfully Requested

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For: Method For Patterning Dielectric Layers On Semiconductor Substrates

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Dear Sir:

The following amendments and remarks are presented in response to the Examiner's Office Action mailed June 28, 2005. Please amend the above-referenced application as follows.